Search Notes

Application/Control No.	Appli Reex
10/665 071	LIN.

Applicant(s)/Patent under
Reexamination
LIN, CHE-WEN
Art Unit

3765

Alissa L. Hoey

Examiner

SEARCHED				
Class	Subclass	Date	Examiner	
2	455, 46	8/17/2005	ALH	
2	22, 23			
2	51, 61			
2	69, 72			
2	82-89			
2	93, 94			
2	101, 242			
2	244, 249			
2	250, 269			
2	911		•	
36	2R	8/17/2005	ALH	

INTERFERENCE SEARCHED					
Class	Subclass	Date	Examiner		
	L				

SEARCH NOTES (INCLUDING SEARCH STRATEGY)			
	DATE	EXMR	
EAST Search	8/17/2005	ALH	
PLUS Search	8/17/2005	ALH	
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